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U.S.S.N. 10/050,322

**JUN 8 0 2005**

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicants: Tsai et al.

Group Art Unit: 1756

Serial No.: 10/050,322

Examiner: N. M. Barroca

Filed: 01/15/2002

In Response to Office Action  
Dated: 04/13/2005For: A BI-LAYER PHOTORESIST DRY DEVELOPMENT AND REACTIVE  
ION ETCH METHOD

Attorney Docket No.: 67,200-613

Certificate of Mailing

I hereby certify that this paper (along with any referred to as being attached or enclosed) is being deposited with the United States Postal Service on the date shown below with sufficient postage as first class mail in an envelope addressed to: Assistant Commissioner for Patents, P.O. Box 1450 Alexandria, Va 22313-1450

R. TUNG

REQUEST FOR RECONSIDERATION  
RE-OPENED PROSECUTION

Commissioner for Patents  
P.O. Box 1450  
Alexandria, Va 22313-1450

Dear Sir:

In response to an Office Action mailed 04/13/2005 please withdraw the finality of action based on newly cited art not of record and allow entry of the following amendments to place the Application in condition for allowance or in better form for Appeal. Please consider the following remarks.

Do  
not  
enter  
7/5/05  
mg